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Serial No. 10/523,844
67222-001

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Kanno et al.
Serial Number: 10/523,844
Filed: February 7, 2005
Group Art Unit: 2812
Examiner: Unknown
Title: WAFER ROTATION DEVICE AND EDGE FLAW
INSPECTION APPARATUS HAVING THE DEVICE

REQUEST FOR CORRECTED FILING RECEIPT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450


Sir:

With respect to the above-identified patent application, applicant respectfully requests a corrected filing receipt.

In the section entitled TITLE, please change "Wafer rotation device and edge flaw inspection apparatus having the device" to --Wafer rotation device and edge flaw inspection apparatus having the device--

Favorable consideration is respectfully requested.

Respectfully submitted,

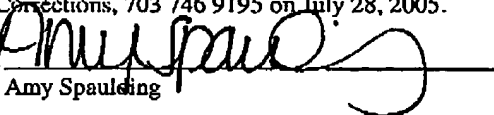


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CERTIFICATE OF FACSIMILE

I hereby certify that this correspondence is being facsimile transmitted to the Commissioner for Patents, Office of Initial Patent Examination's Filing Receipt Corrections, 703 746 9195 on July 28, 2005.



Amy Spaulding

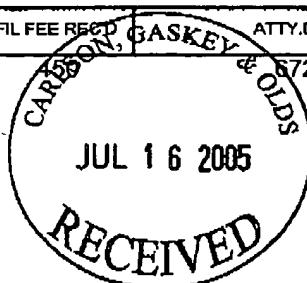


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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/523,844	02/07/2005	2812	4559	67222-001	4	6	1

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CONFIRMATION NO. 4247

FILING RECEIPT



OC000000016479956

Date Mailed: 07/13/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Karin Butchko--45864

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/10166 08/08/2003 ✓

Foreign Applications

JAPAN 2002-234077 08/09/2002 ✓

Projected Publication Date: 10/13/2005

Non-Publication Request: No

Early Publication Request: No

** SMALL ENTITY **

Title

apparatus
Wafer rotation device and edge flaw inspection apparatus having the device

• Preliminary Class
438

PROTECTING YOUR INVENTION OUTSIDE THE UNITED STATES

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